Photochemistry of substituted dibenzothiophene S-oxides and oxygenated bis-dibenzothiophenes Kazuya Kumazoe^a, Kazuya Arima^a, Shuntaro Mataka^b, David J. Walton^c, and Thies Thiemann^{*b}

^aGraduate School of Interdisciplinary Engineering Sciences and ^bInstitute of Advanced Material Study, Kyushu University, 6-1, Kasuga-koh-en, Kasuga-shi 816-8580, Japan ^cThe School of Science and the Environment, Coventry University, Priory Street, Coventry CV1 5FB, UK

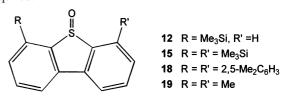
Substituted dibenzothiophene and bis-dibenzothiophene *S*-oxides were prepared and submitted to photolysis. The rate of deoxygenation of the molecules under photoirradiation was found to be highly dependent on their substitution pattern.

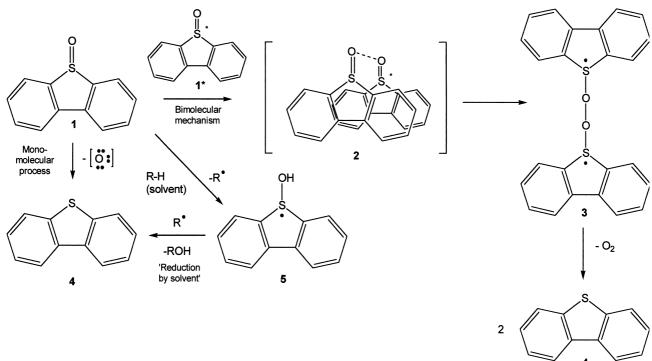
Keywords: dibenzothiophene S-oxides, photochemistry, deoxygenation, sensitisers

Upon photoirradiation, dibenzothiophene *S*-oxides can be deoxygenated. It has been a matter of debate, whether this photodeoxygenation is a mono- or a bimolecular process, a further possibility being a radical mechanism involving solvent molecules. Furthermore, the nature of the released oxygen has been under discussion. In a monomolecular process monoatomic oxygen [most likely O(³P)] would be generated,^{2–4} in the bimolecular process O₂(¹Δ_g).^{5,6} If monoatomic oxygen were liberated in these cases, it has been remarked that this reaction would present a very interesting and clean way to produce a species which thus far has only been studied extensively in the gas phase.

The photodoxygenation has also been observed in simple, non-annelated thiophene *S*-oxides where, however, the outcome of the photoreaction is dependent on the nature of the substituents on the thiophene *S*-oxides.⁸ In this communication, the synthesis and the photo-behaviour of 4-mono- and 4,6-disubstituted dibenzothiophene *S*-oxides as well as of a number of bisdibenzothiophenes, oxygenated at sulfur, are discussed with the aim of determining whether substitution at the vicinity of the sulfoxy-moiety with bulky substituents would have an effect on the photo-deoxygenation of the dibenzothiophene *S*-oxides.

For this purpose, 4-trimethylsilyldibenzothiophene S-oxide (12), 4,6-bis(trimethylsilyl)dibenzothiophene S-oxide (15) and 4,6-bis(2',5'-dimethylphenyl)dibenzothiophene S-oxide (18) were prepared, either by lithiation of dibenzothiophene and reaction with chlorotrimethylsilane (for 12 and 15) or by Suzuki coupling reaction of 4,6-diiododibenzothiophene with 2,5-dimethylphenylboronic acid and subsequent oxidation by *meta*-chloroperoxybenzoic acid of the dibenzothiophenes thus acquired.



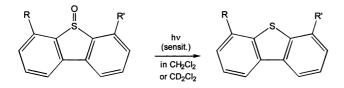


Scheme 1 Possible mechanisms for the photochemical deoxygenation of dibenzothiophene S-oxide.

J. Chem. Research (S), 2003, 60-61 J. Chem. Research (M), 2003, 0248–0263

^{*} To receive any correspondence. E-mail: thies@cm.kyushu-u.ac.jp

The dibenzothiophene S-oxides were photoirradiated in CH₂Cl₂ or in CD₂Cl₂ by using a 1kW high pressure mercury lamp. The reactions were monitored by ¹H NMR spectroscopy. At the end of the reaction, representative samples were purified by chromatography. The standard dibenzothiophene S-oxides, dibenzothiophene S-oxide (1) itself and 4,6-dimethyldibenzothiophene S-oxide (19) deoxygenate smoothly to give dibenzothiophene and 4,6-dimethyldibenzothiophene under these conditions. 4,6-Bistrimethylsilvldibenzothiophene S-oxide (15), however, does not photodeoxygenate at all. Initially, this was thought to indicate that a bimolecular process is involved in the photodeoxygenation, which would be hindered by sterically exacting groups at C-4 and C-6 of the dibenzothiophene S-oxide. In subsequent experiments, however, it could be observed that the equally bulkily substituted 4,6-bis-(2',5'-dimethylphenyl)dibenzothiophene S-oxide (18) deoxygenates efficiently. On the other hand, 4-trimethylsilyldibenzothiophene S-oxide (12), a molecule with only one sterically demanding substituent, rather than with two as in 18, shows a much reduced rate of deoxygenation when compared either to dibenzothiophene S-oxide (1), to 4,6-dimethyldibenzothiophene S-oxide (19), or to 18.

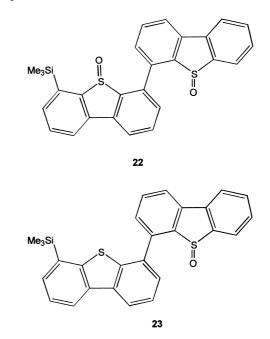


Scheme 2 Photodeoxygenation of dibenzothiophene S-oxides.

Photosensitisers were then added to solutions of 4-trimethylsilyldibenzothiophene *S*-oxide (**12**) and 4,6-bis(trimethylsilyl) dibenzothiophene *S*-oxide (**15**). The addition of 10mol% naphthalene to **12** gave a marked increase of reaction rate when compared to the non-sensitised reaction and the addition of 10mol% benzophenone gave an even greater increase in reaction rate. When 10mol% benzophenone was added to **15**, also **15** photodeoxygenated smoothly, at a rate comparable to that of **12**.

This in itself shows that the reluctance of 4,6-bis-(trimethylsilyl)dibenzothiophene S-oxide (15) to deoxygenate in a non-sensitised reaction may not involve an inability to form a dimeric structure necessary for the deoxygenation, but may be either caused by an ineffective intersystem crossing or due to the short lifetime of the triplet state itself. Interestingly, when 10mol% 4,6-dimethyldibenzothiophene was added to 12, again a rate acceleration, similar to that observed with naphthalene added as sensitiser, was noted when compared to the non-sensitised irradiation, which indicates that the photodeoxygenation of certain dibenzothiophene S-oxides is selfcatalysing. This has been seen in the photoirradiation of some monomeric thiophene S-oxides, such as 2,3,4,5-tetramethylthiophene S-oxide, and of thienylthiophene S-oxides.9 Also, the addition of 4,6-dimethylbenzothiophene to 4,6-bis-(trimethylsilyl)-benzothiophene S-oxide (15) led to deoxygenation of the dibenzothiophene *S*-oxide, which is unreactive in the absence of additive (see above).

When the oxygenated dibenzothiophene-dimers 22 and 23 were photoirradiated under the same conditions, the rates of deoxygenation were remarkably different. While the deoxygenation of 23 was complete within 4h, the photodeoxygenation of 22 took 19h hours to complete. Here, a contributing factor may be the catalytic effect of the (non-oxidised) thiophene unit in 23.



Techniques used: IR, ¹H NMR, ¹³C NMR, LRMS, HRMS, UV-VIS, column chromatography, HPLC, photo-irradiation

References: 17

Schemes: 6

Figures: 4 (reaction/time plots: 3)

Received 24 August 2002; accepted 16 January 2003 Paper 02/1525

References cited in this synopsis

- 2 (a) Z. Wan and W.S. Jenks, J. Am. Chem. Soc., 1995, 117, 2667;
 (b) D.G. Gregory, Z. Wan and W.S. Jenks, J. Am. Chem. Soc., 1997, 119, 94.
- 3 E. Lucien and A. Greer, J. Org. Chem., 2001, 66, 4576.
- 4 J.W. Cubbage, T.A. Tetzlaff, H. Groundwater, R.D. McCulla, M. Nag and W.S. Jenks, J. Org. Chem., 2001, **66**, 8621.
- 5 G.M. Gurria and G.H. Posner, J. Org. Chem., 1973, 38, 2419.
- 8 T. Thiemann, D. Ohira, K. Arima, T. Sawada, S. Mataka, F. Marken, R.G. Compton, S.D. Bull and S.G. Davies, *J. Phys. Org. Chem.*, 2000, **13**, 648.
- 9 T. Thiemann, K. Kumazoe, K. Arima and S. Mataka, *Rep. Inst. Adv. Mat. Study, Kyushu Univ.*, 2001, **15**, 63; *Chem. Abstr.*, 2001, **134**, 173 925u